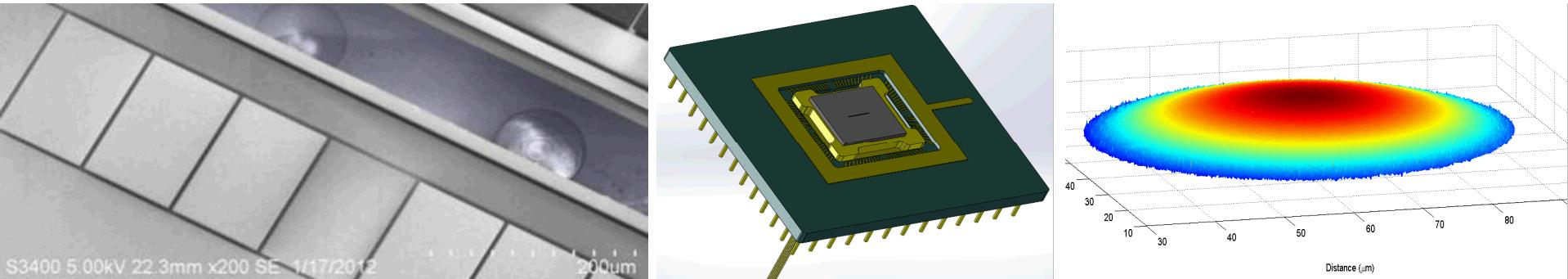


Exceptional service in the national interest



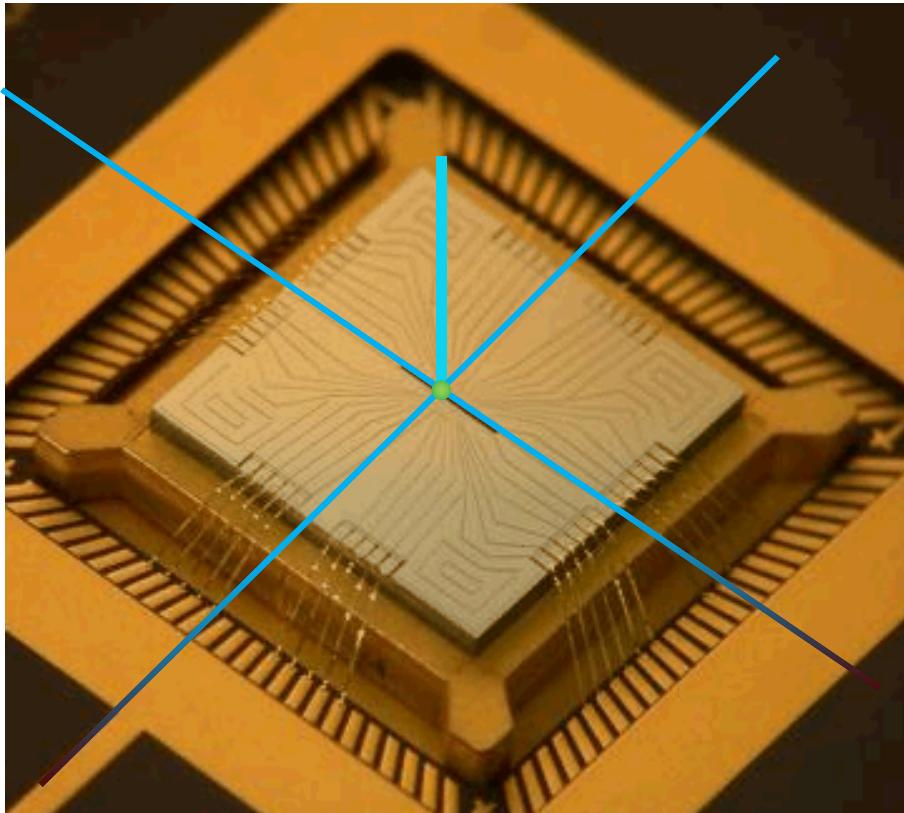
Micro-optical grayscale excitation lens for atom and ion trapping

D.A. Scrymgeour, S.A. Kemme, R.R. Boye,
A.R. Ellis, T.R. Carter, S. Samora, J.D. Hunker



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Using integrated optics to deliver light to surface trapped ions



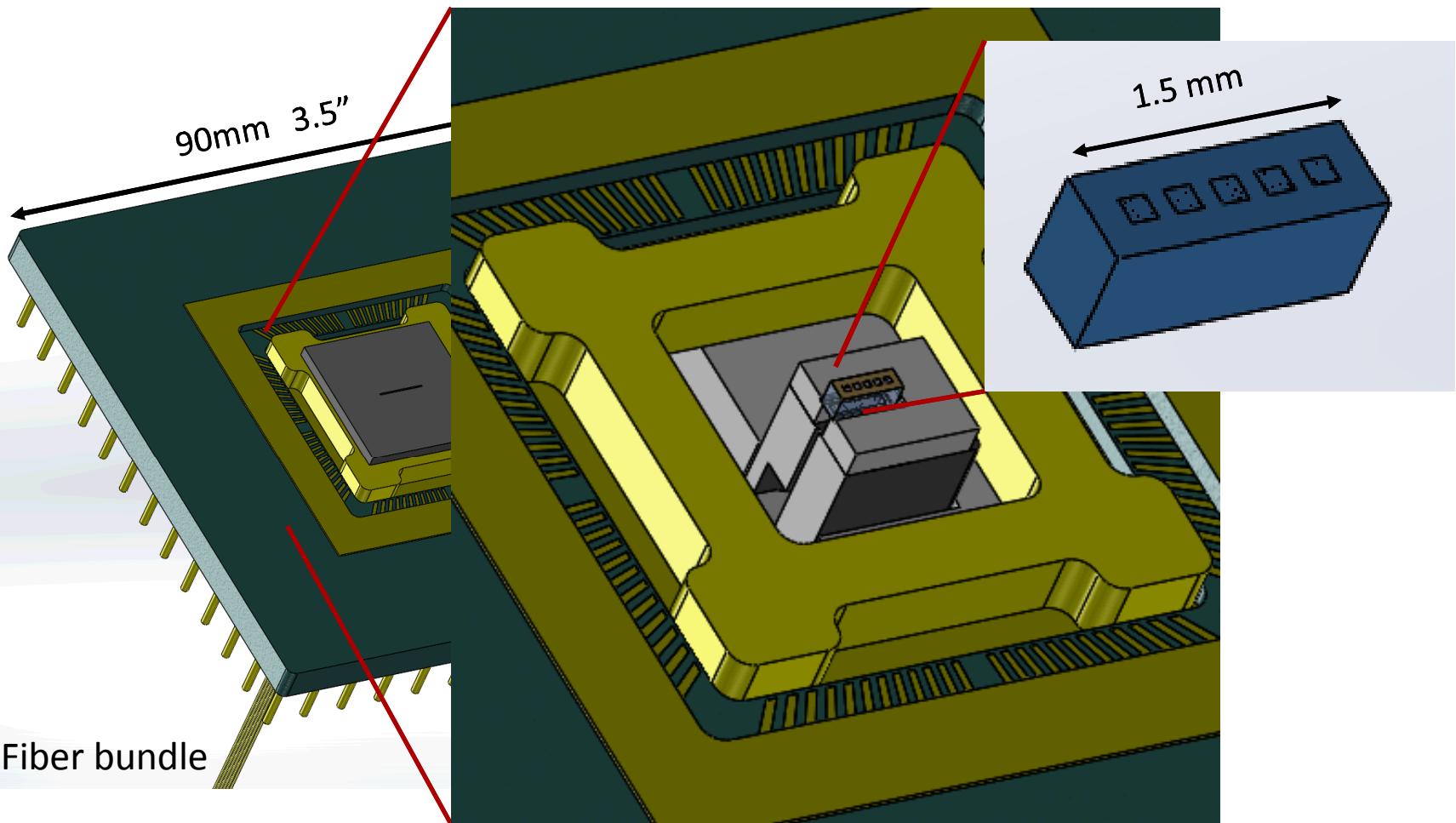
- Increase NA of lenses
- More light delivered / collected
- Increase speed of computation
- Miniaturization of system

Optical system requirements:

- Wavelength 397 nm
- Bake-out at 200-250°C
- UHV operation

Fused silica

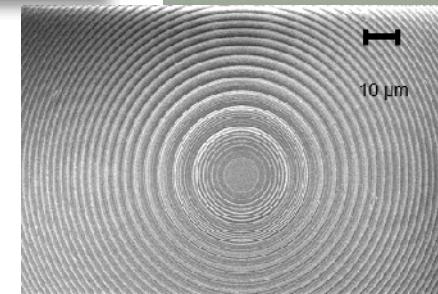
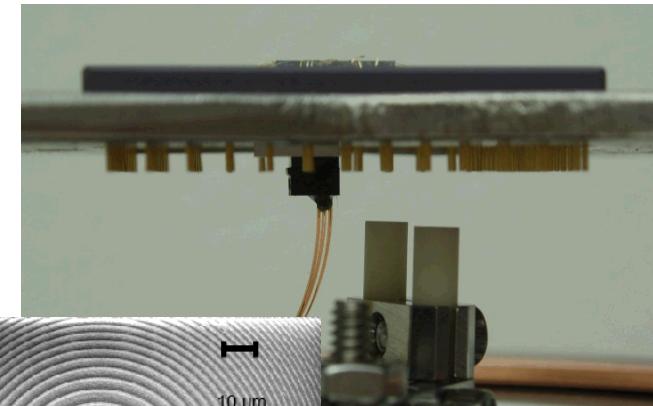
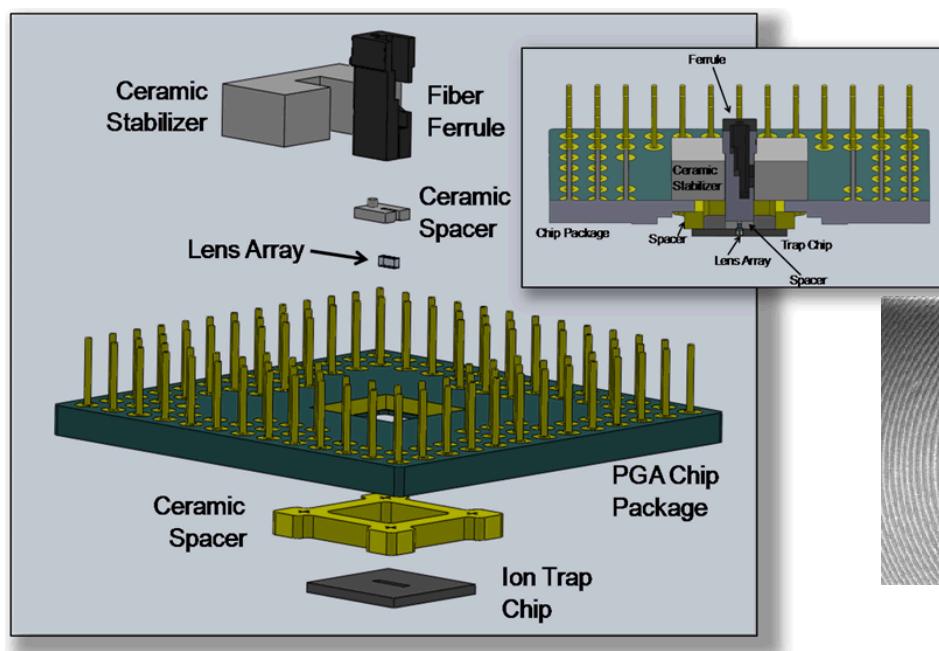
Micro-optics layout



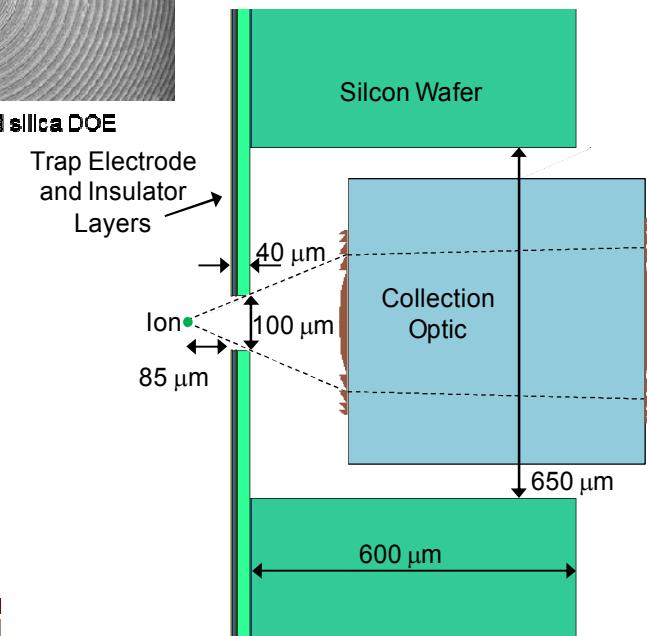
Fiber bundle

1.5 mm

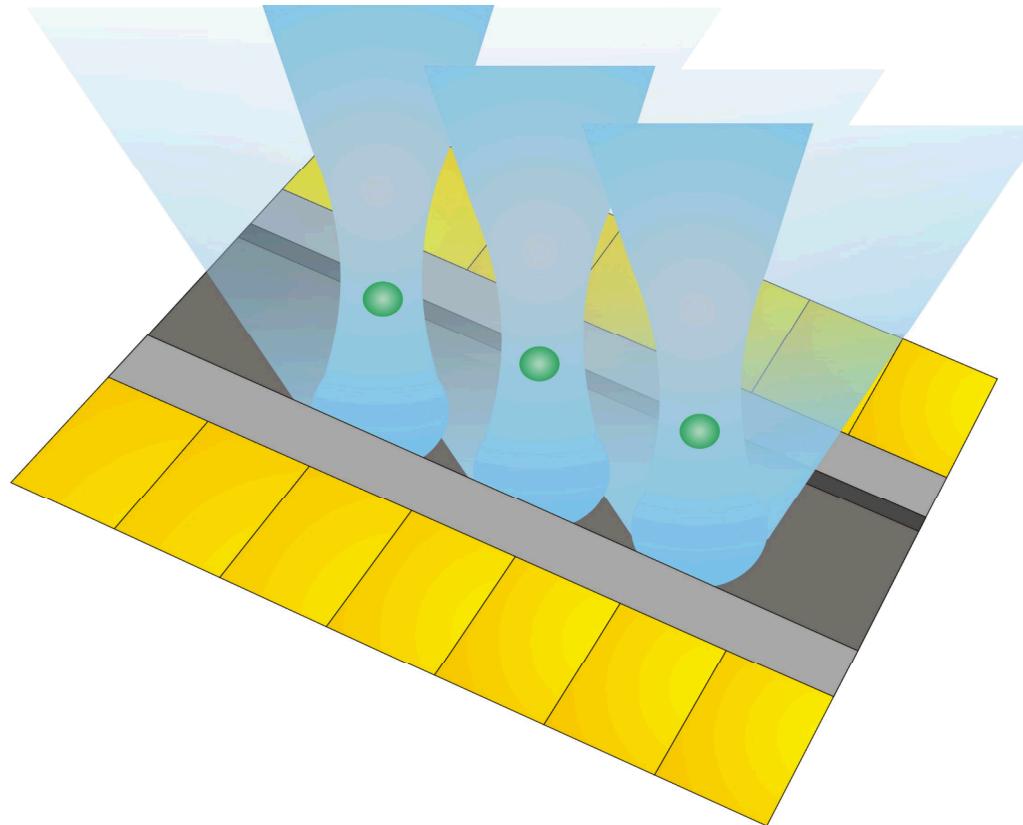
Previously demonstrated diffractive collection & excitation lenses



- Optics have been integrated into linear ion trap.
- No detrimental effects to ultra-high vacuum.
- Dielectric lenses ~150 microns away from ion.



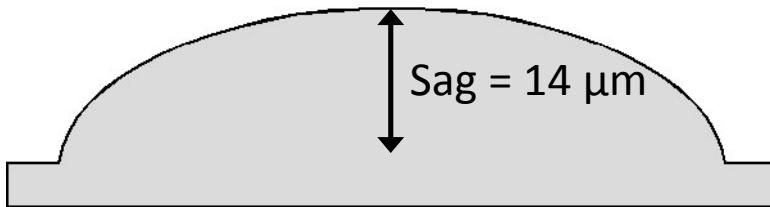
Concern that diffractive excitation optic would detrimentally scatter light



- Excitation – lots of light
- Ions inherently sensitive to scattered light
- Impact ultimate density of trapped ions

Refractive grayscale optics offer higher efficiency & lower scatter

Grayscale Transmissive Lens



Cross Section, bulk patterning

Diffractive Lens

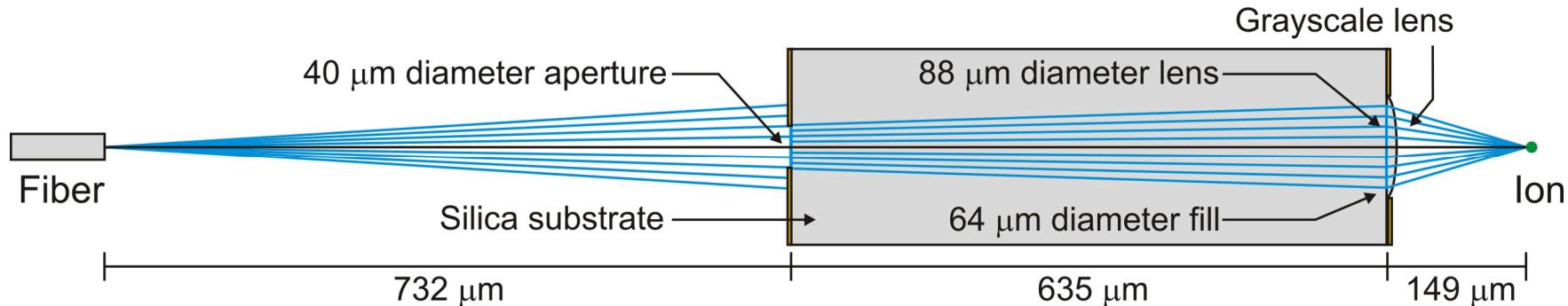


Cross Section, Surface patterning

Grayscale also offers (unlike reflow):

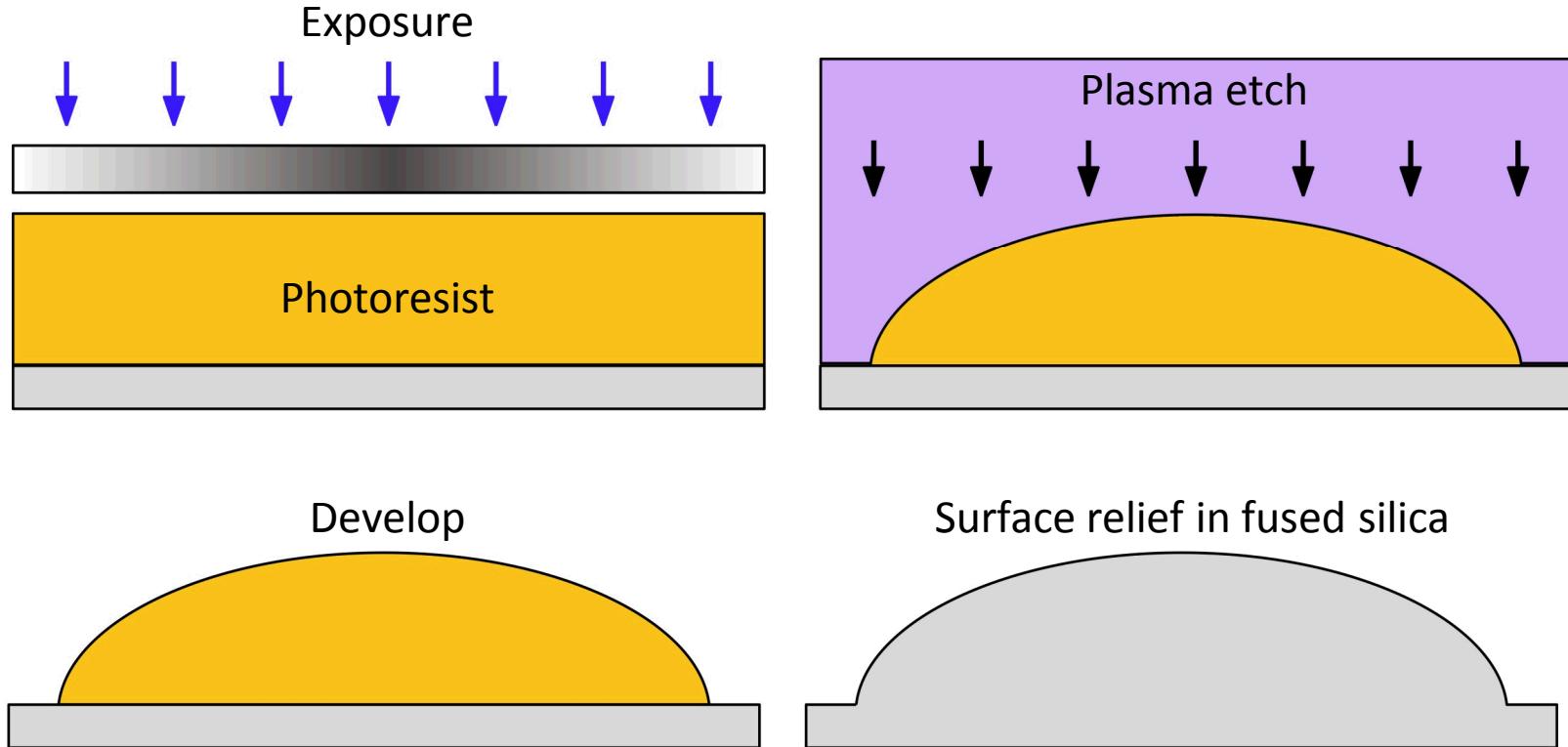
- Aspherical and off-axis capabilities
- 100% fill factor
- Concave shapes (divots)

Design equivalent refractive lens to match performance of diffractive lens



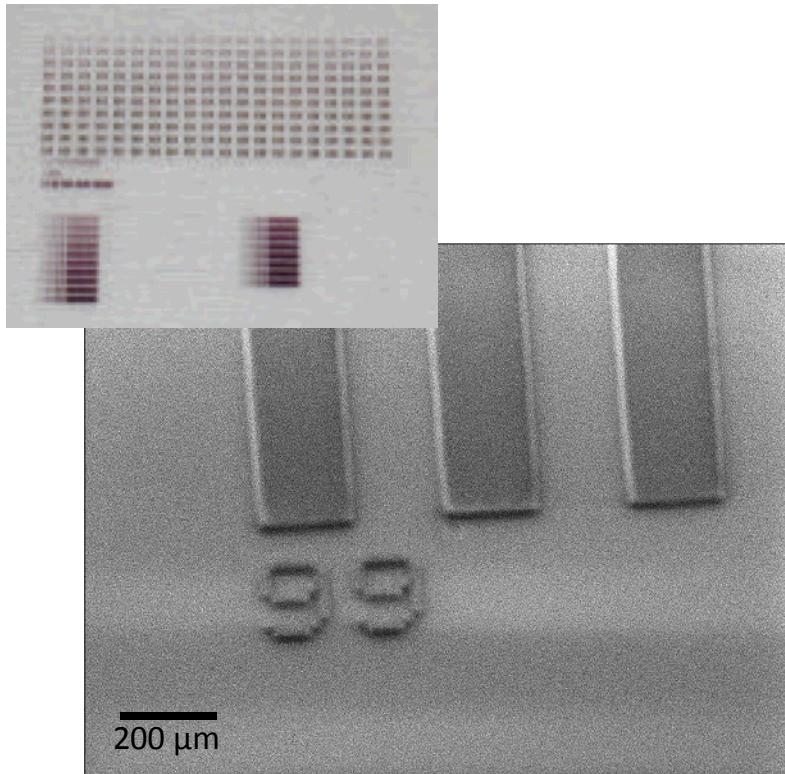
- High efficiency, precision ion illumination with lowest signal outside of focal position – lowest “scatter” over ion field
- Single surface optic, diffraction limited over a 5 micron field
- Surface Sag = 14.2 μm

Grayscale processing creates surface relief in one exposure step

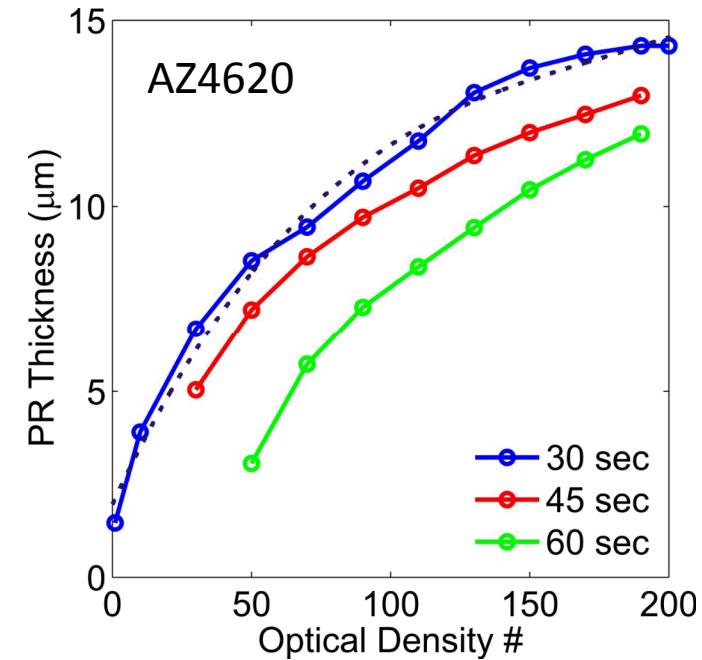


Iterative process to relate developing conditions to final PR thickness

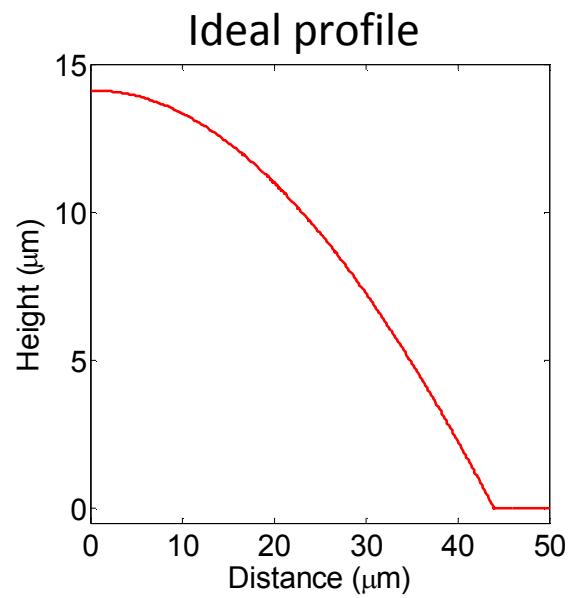
Calibrated test structures



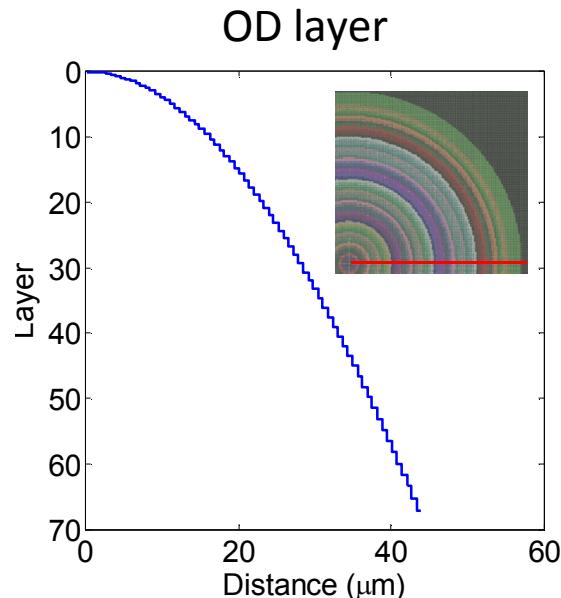
PR Spin Thickness
Exposure Conditions
Development time



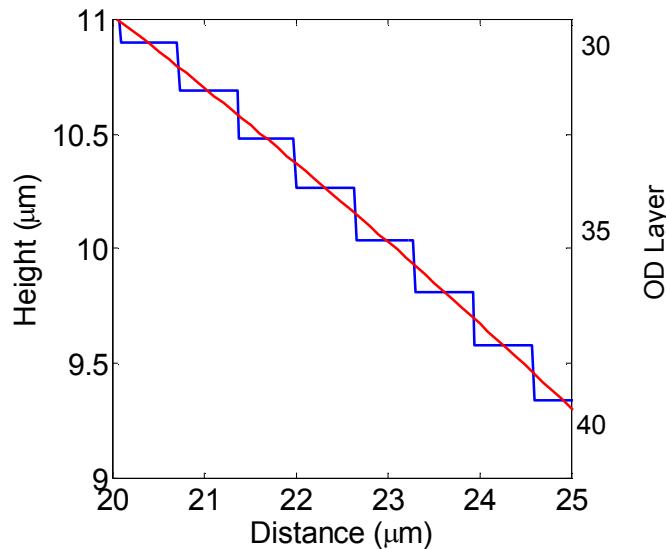
Mask design and fabrication once calibration process is complete



88 optical density levels
Pixel size of 500 nm



Fracture in constant horizontal steps of varying heights



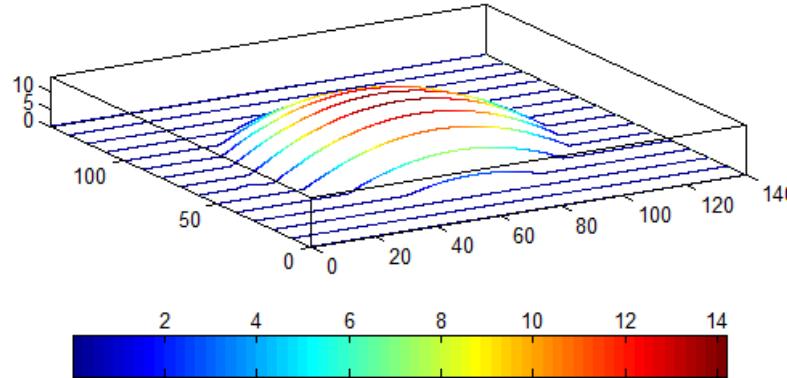
Conic aspherical microlens

Sag	14.16 μm
Lens Diameter	88 μm
Radius of curvature	62.3 μm
Conic constant	-1.851

Masks fabricated by both
Canyon Materials & University of Delaware

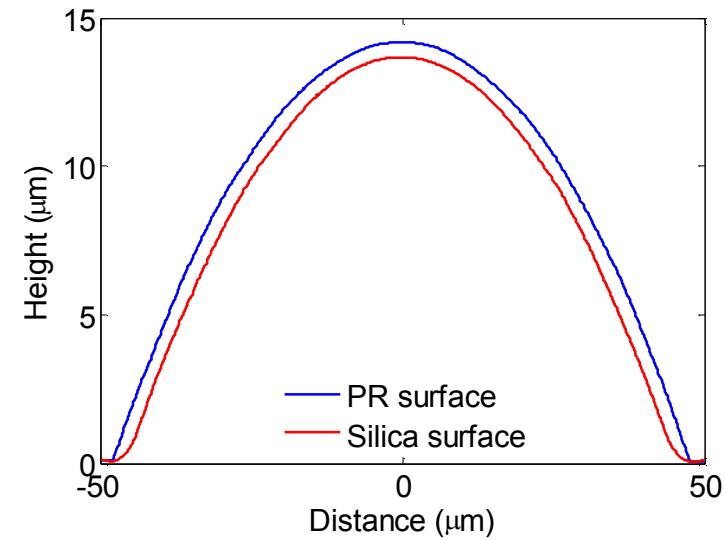
RIE used to transfer smooth PR features to fused silica substrate

Stylus profilometry of PR surface



Etch depth 14.2 μm
Etch rate $\sim 2.5 \text{ nm/sec}$ (90 min etch)
Selectivity (Silica/PR) 1.05:1 – 1.2:1

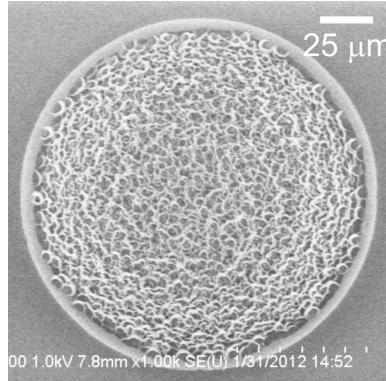
Plasma-Therm Versaline ICP
ICP conditions: $\text{CHF}_3:\text{CF}_4:\text{Ar}$ (3:4:4)
ICP power 810 W Bias Forward power 120 W
Backside He cooling



Temperature control of substrate vital for proper etching

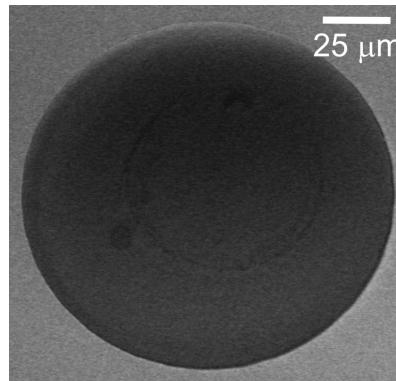
Fused silica wafer mounted to a cooled silicon wafer submount

Improper
temperature
control



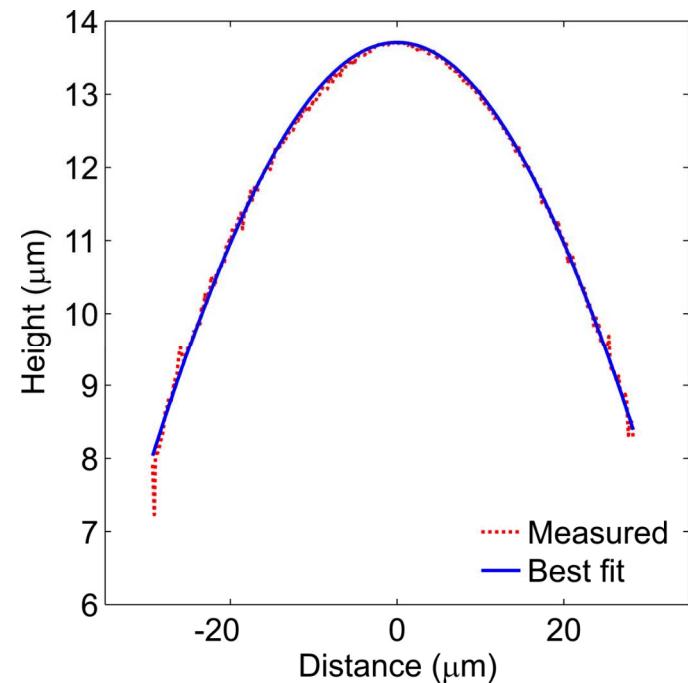
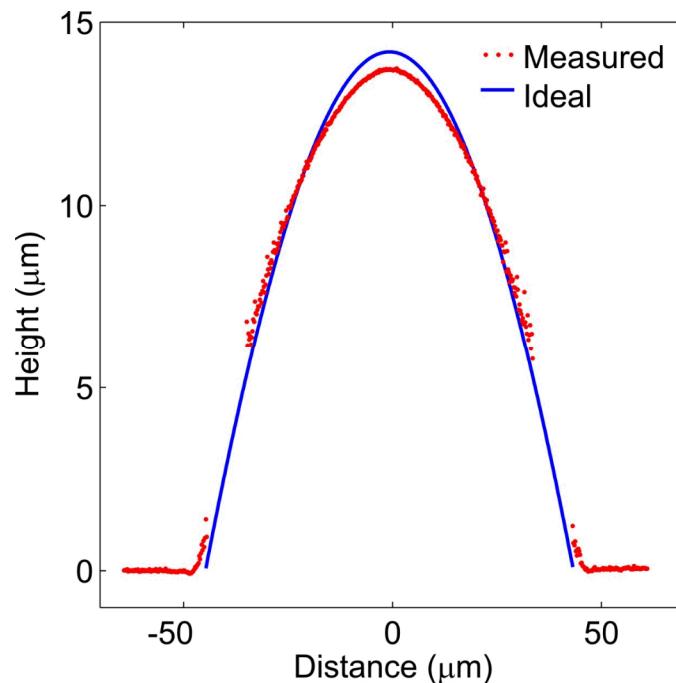
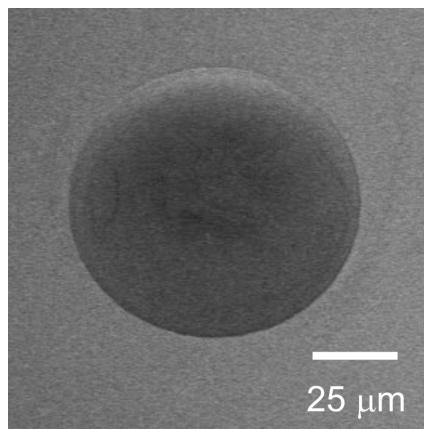
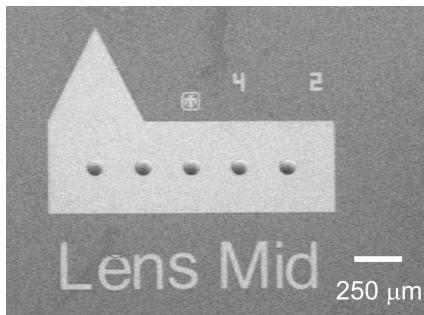
Non uniform etching
Pitting and PR damage

Successful
temperature
control



Best T control we could achieve:
Etch selectivity (Silica/PR) 1.05-1.2 : 1
Variable surface roughness (5 – 50 nm RMS)

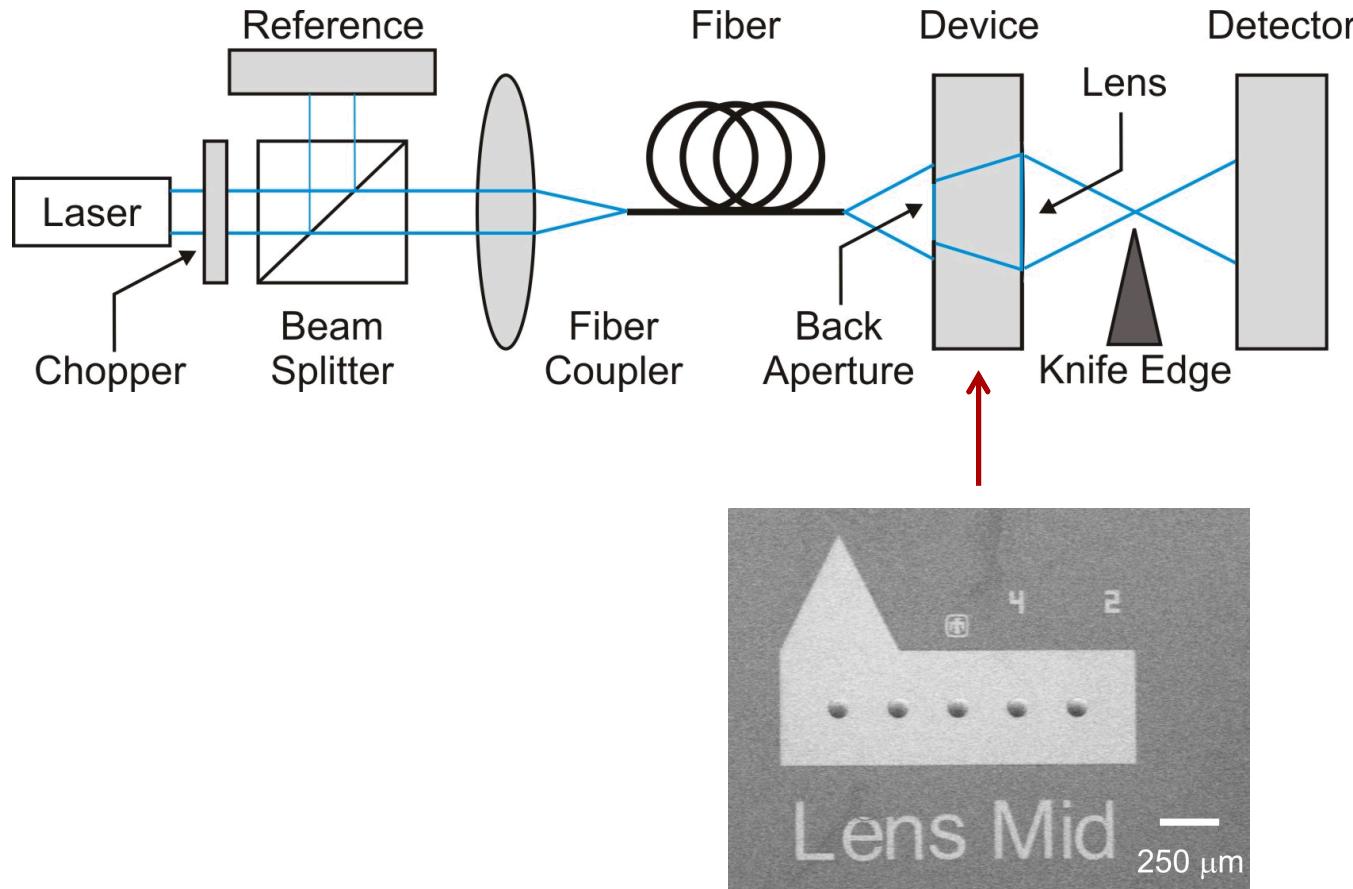
Successful lens transfer into silica



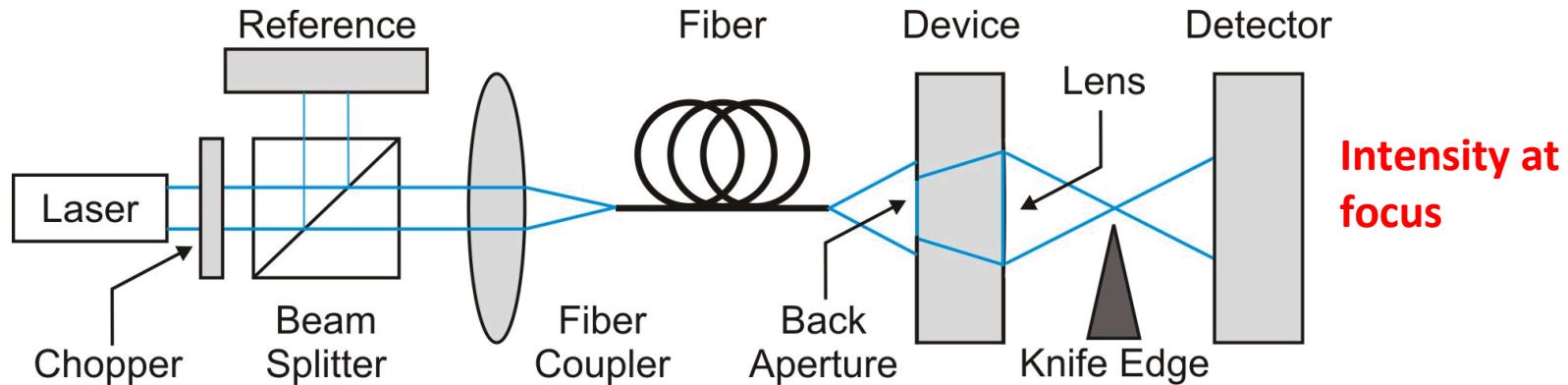
Radius of curvature	$62.3\text{ }\mu\text{m}$
Conic constant	-1.851

Radius of curvature	$69.8\text{ }\mu\text{m}$
Conic constant	-3.082

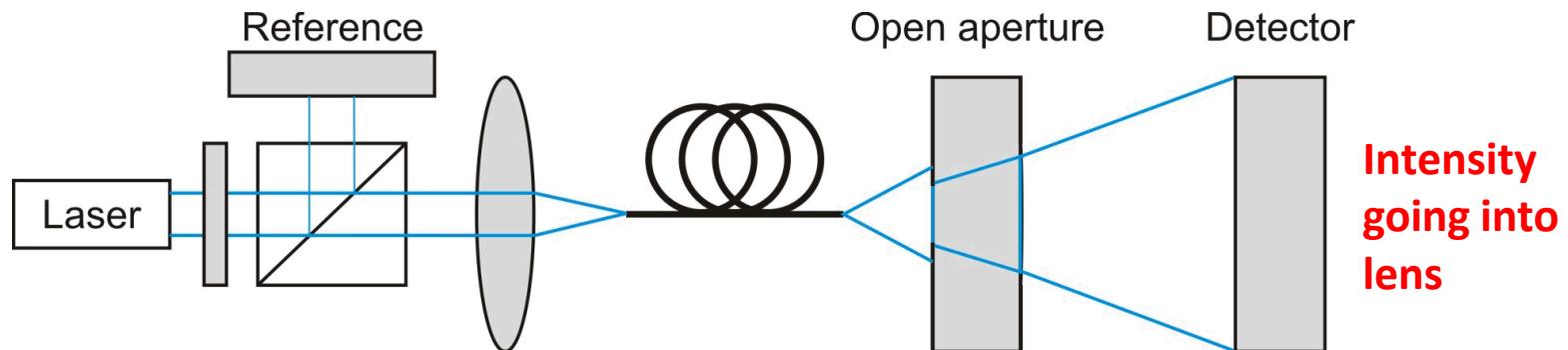
Focal distance and focus size was determined by knife edge measurements



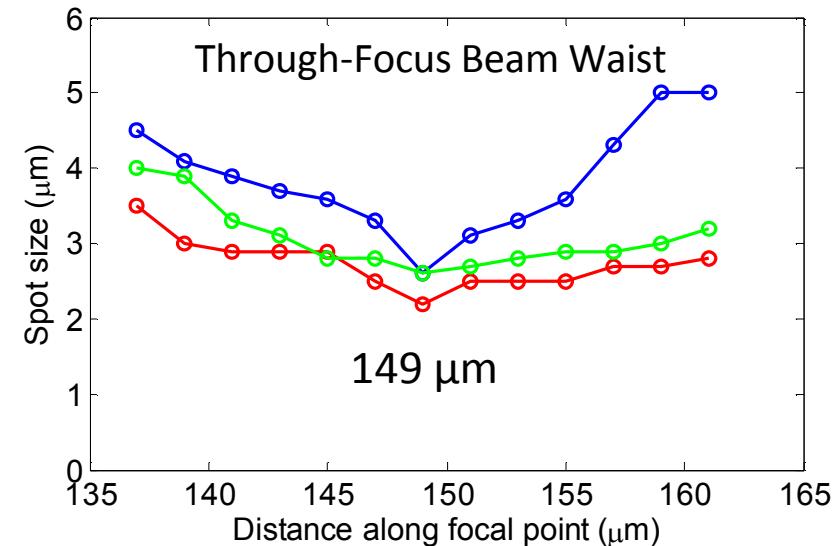
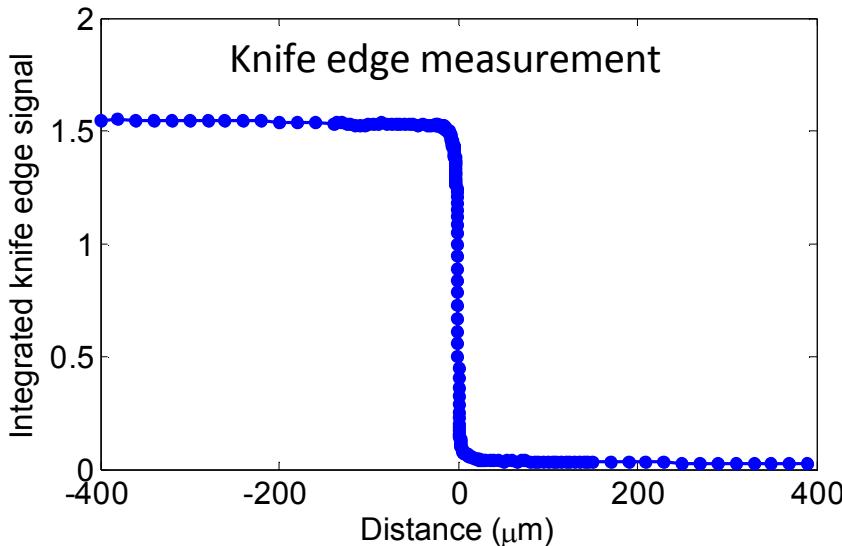
Efficiency estimated by comparing lens to open aperture



Vs.



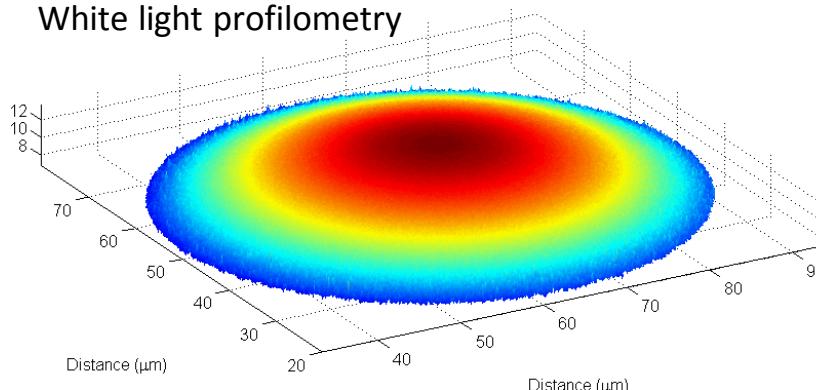
Grayscale lens performance was exactly as designed



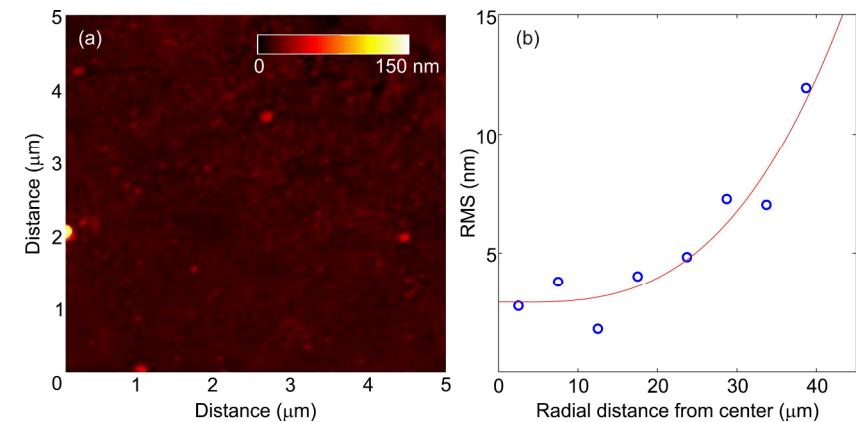
- Knife-edge measurements of spot size through focus => 2.6 microns diameter
- At-spec focus position => 149 microns
- Theoretical grayscale lens efficiency is 92%
- Knife-edge measurement of efficiency => 79% (86% of theoretical, loss due to some rms roughness?)

Roughness of lens surface critical to low scatter performance

White light profilometry



Noncontact AFM measures



As tested lens:

Roughness (RMS): ~ 36 nm

Diffuse scatter losses of $\sim 7\%$

Best lens surface:

Roughness (RMS): ~ 5 nm

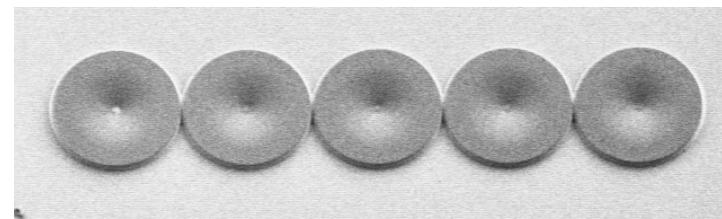
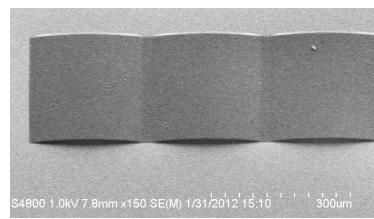
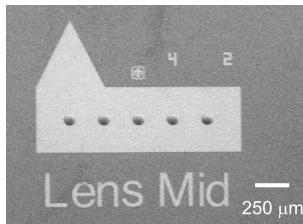
Diffuse scatter losses of $< 0.1\%$

Need to hit these values for optimal performance



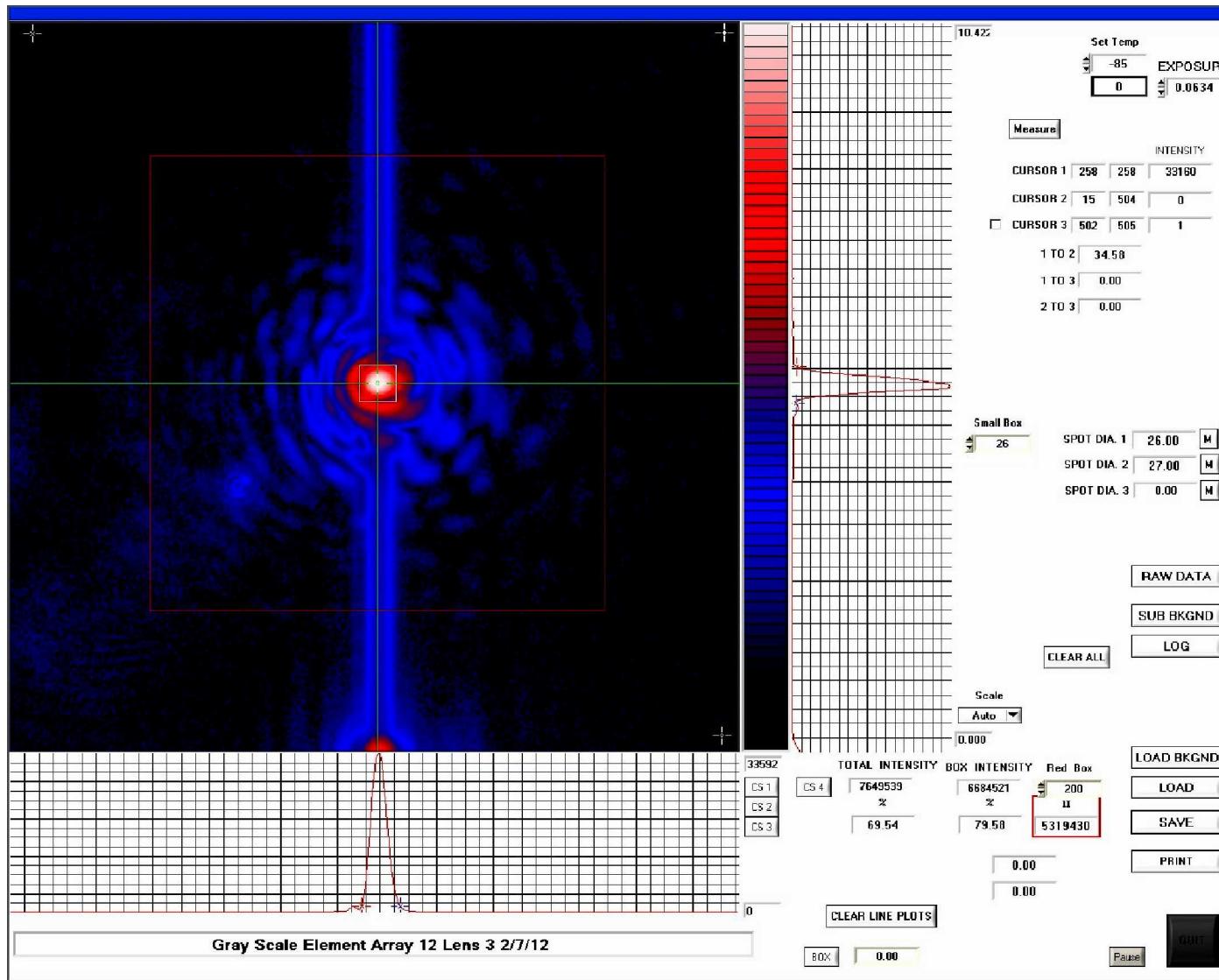
Conclusions

- Designed and fabricated **grayscale** equivalent excitation optic for single mode fiber coupling with low scatter and high efficiency for trapped ion
- Successfully developed process to realize grayscale micro-optics in fused silica with **off-axis capabilities** and **precision aberration control** for **100% full-filled** lens arrays
- Characterized grayscale excitation micro-lens arrays that produce:
 - high-efficiency (~79%),
 - as-designed focal position (149 microns)
 - near-diffraction limited focused spots (2.6 microns)
 - Surface roughness critical for ion trapping applications



The End

Grayscale Excitation Lens Focused Spot Showing Airy Rings (Log-scale to enhance low-light detail)



Simulations

